

AMENDMENTS TO THE CLAIMS

Please **CANCEL** claim 3 without prejudice or disclaimer.

Please **AMEND** claims 1, 2, 4-20 and 56 as shown below.

The following is a complete list of all claims in this application.

1. (Currently Amended) An in-line system for manufacturing liquid crystal displays, comprising:
 - a sealant-applying unit for depositing sealant on one of two substrates, either one of the two ~~substrate~~ substrates having at least one liquid crystal cell;
 - a sealant heat-treating unit forming a reaction-prevention layer on a surface of the sealant to prevent a reaction between the sealant and a liquid crystal material;
 - a liquid crystal depositing unit for depositing the liquid crystal material on the substrate where the sealant is deposited; and
 - a substrate-attaching unit for receiving the two substrates from the sealant-applying unit or the liquid crystal depositing unit, ~~then~~ and conjoining the substrates in a vacuum state; and
 - an in-line convey unit conveying the substrates in the in-line system.

2. (Currently Amended) The in-line system of claim 1, further comprising:
 - a first loading unit ~~where~~ loading one of the two substrates ~~is loaded, and;~~

a second loading unit ~~where one~~ loading the other one of the two substrates is loaded; and

a substrate-combination unit ~~for~~ providing the two substrates to the substrate-attaching unit.

3. (Cancelled)

4. (Currently Amended) The in-line system of claim 3 2, wherein the first loading unit, the spacer-dispersing unit, the sealant-applying unit, the liquid crystal depositing unit, the substrate-combination unit, and the substrate-attaching unit are ~~combined~~ arranged in series ~~in this sequence through first, second, third, fourth and fifth in-line conveying units, which transport the substrates to these elements in predetermined in-line process time units.~~

5. (Currently Amended) The in-line system of claim 4, wherein the second loading unit is connected to the substrate-combination unit ~~through a sixth in-line conveying unit.~~

6. (Currently Amended) The in-line system of claim 3 2, wherein the first loading unit, the sealant-applying unit, the liquid crystal depositing unit, the substrate-combination unit, and the substrate-attaching unit are ~~combined~~ arranged in series ~~in this sequence through first, second, third and fourth in-line conveying units, which transport the substrates to these elements in predetermined in-line process time units.~~

7. (Currently Amended) The in-line system of claim 6, wherein the second loading unit, the spacer-dispersing unit and the substrate-combination unit are ~~connected~~ arranged in series ~~sequence through fifth and sixth in-line conveying units.~~

8. (Currently Amended) The in-line system of claim 1, wherein the substrate-attaching unit includes two or more vacuum chambers ~~for conjoining the substrates in a vacuum state in a predetermined in-line process time unit.~~

9. (Currently Amended) The in-line system of claim 8, wherein the vacuum chambers are ~~connected~~ arranged in series ~~such that the substrates are provided to a subsequent process in a predetermined vacuum state, each vacuum chamber holding the substrates for a predetermined in-line process time.~~

10. (Currently Amended) The in-line system of claim 8, wherein the vacuum chambers are ~~connected~~ arranged in parallel ~~such that the substrates are provided to a subsequent process in a predetermined vacuum state, each vacuum chamber holding the substrates for a predetermined in-line process time.~~

11. (Currently Amended) The in-line system of claim 1, wherein the substrate-attaching unit ~~includes~~ comprises:

a first compression plate and a second compression plate for supporting the two substrates and applying a predetermined force toward each other ~~such that the two substrates are pressed together~~; and
an exposure unit for hardening the sealant.

12. (Currently Amended) The in-line system of claim 1, wherein the substrate-attaching unit ~~includes~~ comprises:

a first compression plate and a second compression plate for supporting the two substrates and applying a predetermined force toward each other ~~such that the substrates are pressed together~~, the first compression plate and the second compression plate having at least one vacuum hole for exhausting air from between the compression plates;

a support tube provided between the first compression plate and the second compression plate for sealing a space therebetween, the support tube having an inner space for exhausting air ~~can be exhausted such that to adjust~~ an interval between the first compression plate and the second compensation plate ~~plates can be adjusted~~; and
an exposure unit for hardening the sealant.

13. (Currently Amended) The in-line system of claim 12, wherein the substrate-attaching unit has a plurality of the vacuum holes at predetermined locations, ~~and air is exhausted from the vacuum holes~~ for exhausting in a predetermined sequence.

14. (Currently Amended) The in-line system of claim 13, wherein the vacuum holes are formed at corners or a center portion ~~portions~~ of each side of the first compression plate and the second compression plate.

15. (Currently Amended) The in-line system of claim 13, wherein the vacuum holes are ~~shaped as slits of~~ having a predetermined length.

16. (Currently Amended) The in-line system of claim 1, wherein the liquid crystal depositing unit ~~includes~~ comprises a syringe-type liquid crystal depositer ~~that is a syringe-type device such that~~ for depositing the liquid crystal material ~~can be deposited~~ at specific predetermined locations in the liquid crystal cell.

17. (Currently Amended) The in-line system of claim 1, wherein the liquid crystal depositing unit comprises is a spray-type liquid crystal depositer ~~device such that~~ for depositing the liquid crystal material ~~can be deposited~~ over an entire surface of the liquid crystal cell.

18. (Currently Amended) The in-line system of claim 1, wherein the sealant-applying unit deposits the sealant in a closed loop, ~~that is,~~ without a liquid crystal injection hole.

19. (Currently Amended) The in-line system of claim 1, wherein the sealant is ~~a material that is~~ hardened by infrared rays.

20. (Currently Amended) The in-line system of claim 1, wherein the sealant includes one or more buffer regions ~~that have a predetermined area~~ to allow for flow of excess liquid crystal material.

21. (Withdrawn) A liquid crystal depositing unit for manufacturing a liquid crystal display, comprising:
a depositer for depositing liquid crystal material in liquid crystal cell of one of two substrates of a mother glass.

22. (Withdrawn) The liquid crystal depositer of claim 21, wherein said depositer is a syringe-type device such that the liquid crystal material can be deposited at specific predetermined locations in the liquid crystal cell.

23. (Withdrawn) The liquid crystal depositer of claim 21, wherein the depositer is a spray-type device having a plurality of nozzles such that the liquid crystal material can be deposited over an entire surface of the liquid crystal cell.

24. (Withdrawn) A substrate-attaching unit for manufacturing a liquid crystal display, the substrate-attaching unit attaching, in a vacuum state, two substrates of a mother glass having at least one liquid crystal cell region.

25. (Withdrawn) The substrate-attaching unit of claim 24, wherein the substrate-attaching unit includes a first compression plate and a second compression plate for supporting the two substrates and applying a predetermined force toward each other such that the substrates are pressed together; and an exposure unit for hardening a sealant between the substrates.

26. (Withdrawn) The substrate-attaching unit of claim 24, further comprising:
a first compression plate and a second compression plate for supporting the two substrates and applying a predetermined force toward each other such that the substrates are pressed together, a first compression plate and the second compression plate having at least one vacuum hole for exhausting air from between the compression plates;

a support tube provided between the compression plates for sealing a space therebetween, the support tube having an inner space from which air can be exhausted such that an interval between the compression plates can be adjusted; and
an exposure unit for hardening the sealant.

27. (Withdrawn) The substrate-attaching unit of claim 26, wherein there are provided a plurality of the vacuum holes at predetermined locations, and air is exhausted from the vacuum holes in a predetermined sequence.

28. (Withdrawn) The substrate-attaching unit of claim 27, wherein the vacuum holes are formed at corners or center portions of each side of the first compression plate and the second compression plate.

29. (Withdrawn) The substrate-attaching unit of claim 28, wherein the vacuum holes are shaped as slits of a predetermined length.

30. (Withdrawn) The substrate-attaching unit of claim 24, wherein the substrate-attaching unit includes two or more vacuum chambers for conjoining the substrates in a vacuum state in a predetermined in-line process time unit.

31. (Withdrawn) The substrate-attaching unit of claim 30, wherein the vacuum chambers are connected in series such that the substrates are provided to a subsequent process in a predetermined vacuum state, each vacuum chamber holding the substrates for a predetermined in-line process time.

32. (Withdrawn) The in-line system of claim 30, wherein the vacuum chambers are connected in parallel such that the substrates are provided to a subsequent process in a predetermined vacuum state, each vacuum chamber holding the substrates for a predetermined in-line process time.

33-55. (Cancelled)

56. (Currently Amended) The in-line system of claim 1, further comprising a spacer-dispersing unit for dispersing spacers on either one of two substrates.